Coatings for the Einstein Telescope

J. Steinlechner ET Symposium - 3 Dec 2020





Coating Basics

Highly-reflective coatings

- stack of many layers; usually two materials with different refractive index n
- ➢ optical layer thickness: quarter of a wavelength (= higher n → thinner layer)

Example: SiO₂ (blue, n=1.45) and Ta₂O₅ (green, n=2.05)

- > ~38 layers needed for highly reflective ETMs of R = 99.9995%
- light intensity reduces with every layer pair
- > ITMs, lower reflectivity \rightarrow fewer layers (about half of ETN

Requirements:

- Low coating thermal noise (CTN):
 - limiting noise source \rightarrow needs to get reduced
- Low optical absorption: few parts per million (10⁻⁶)
 - to avoid heating
 - to avoid thermal deformations
- Low scattering (from e.g. defects or micro crystals)
 - only purely amorphous or single-crystalline materials suitable





Coating thermal noise



mirror temperature

mirror temperature (depends on reflectivity and refractive indices)

Coating thermal noise

- frequency dependent
- lower for larger beams
- temperature dependent
- determined by material properties (coating and substrate)
- \rightarrow Cooling at low f where CTN is high!



beam radius (on mirror)

coating mechanical loss

- 1. ET low-frequency (LF) detector
 - a. low temperature (10K, 20K or 120K?))
 - b. low laser power (to minimize heating from absorption)
 - c. fused silica unsuitable at low temp. due to high thermal noise: change to crystalline silicon (or sapphire)
 - d. silicon requires longer wavelength (1550nm or ~2000nm?)
- 2. ET high-frequency (HF) detector
 - a. same substrate material, temperature and laser wavelength as LIGO and Virgo detectors
 - b. can tolerate high laser power to reduce quantum noise
- \rightarrow both LF and HF require new coating solutions!



ET HF (same wavelength, substrate material and temperature as LIGO and Virgo detectors)

- Orange line: Using <u>aLIGO/AdvVirgo coatings</u> in ET-HF
 - Reduction from longer arms and larger beams
- Red dashed line: ET-HF design
- Planned A+ coatings will meet ET-HF design
 - Likely candidates to achieve this goal: <u>TiO₂: GeO₂ or TiO₂:SiO₂ to replace TiO₂:Ta₂O₅ as high-n material, (currently ~20% above ET-HF goal)
 </u>
 - Still to be confirmed: low absorption and mechanical loss of multilayers
- AdV+ looking into SiN as a high-n material
 - Similar mechanical loss to TiO_2 : GeO_2 , but thinner coatings from higher n \rightarrow meets ET-HF goal
 - <u>SiN R&D in Taiwan</u>, Virgo groups working on absorption reduction of IBS SiN
- R&D and implementation for A+/AdvV+: Best test!

Remaining challenges: Upscaling coating diameter by almost a factor of two (bubble- and defect-free)

ET-HF design (2020 update)





ET-LF (using 1550nm and 20K for calculations)

- Orange line: Current LIGO/Virgo coatings cooled: mechanical loss of SiO₂ and TiO₂:Ta₂O₅ increases
 → less improvement than expected from low temp. (note different x range)
- Pink line: (undoped) GeO₂ and SiO₂: increasing loss \rightarrow CTN increase
- \succ Green line: SiN and SiO₂
 - limited by SiO₂ loss
 - \rightarrow less CTN improvement than at room temp.

Low temperatures: We need a factor of two CTN reduction. Different low-n material needed (or fewer SiO, layers)!

ET-LF design (2020 update)





ET-LF (using 1550nm and 20K for calculations)

- Orange line: Current LIGO/Virgo coatings cooled (for comparison)
- Blue: SiO₂/aSi coatings few layers due to high n of aSi

<u>~8ppm coating absorption</u> \rightarrow too high + further R&D needed for reproducibility absorption lower at 2um (slight CTN increase from thicker layers)







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- 10K: CTN reduces further, but we can tolerate even less absorption

Other options:

- Nanolayers: Can suppress cryogenic loss peaks (suppressing structural changes with annealing? Layers thinner than structural units responsible for loss?)
- Other materials: Structural predictions
- Multimaterial coatings

ET-LF design (2020 update)





Multimaterial Coatings - a trade-off of absorption and CTN



absorption @ 1550nm [ppm]

- Use some low-absorbing SiO₂/TiO₂:Ta₂O₅ at the top to reduce laser power, high-absorbing aSi only used further down
- each point represents one aSi layer added
- trade-off between CTN decrease and absorption increase



Due to high *n*, replacing one Ta_2O_5 layer by aSi, allows to remove additional SiO_2/Ta_2O_5 for *R* = const.

Coating Solution for ET-LF





Coating Solution for ET-LF?

- meets CTN design of ET-LF at 10K \succ
- uses 2 x SiO₂/TiO₂:Ta₂O₅ on top of aSi and SiO₂:HfO₂ \succ
- absorption = 3.4 ppm per mirror \succ
 - < 5ppm: target in initial (2011) ET design study Ο
 - more recently: absorption ideally lower 0

- but how low?



Maastricht University PHYSICAL REVIEW LETTERS Highlights Referees Collections Authors Mirror Coating Solution for the Cryogenic Einstein Telescope Kieran Craig, Jessica Steinlechner, Peter G. Murray, Angus S. Bell, Ross Birney, Karen Haughian, Jim Hough, Ian MacLaren, Steve Penn, Stuart Reid, Raymond Robie, Sheila Rowan, and Iain W. Martin Phys. Rev. Lett. 122, 231102 - Published 13 June 2019 PhySICS See Synopsis: Mirror, Mirror-Which Coating is the нтм Article References Citing Articles (3) > ABSTRAC1 Planned cryogenic gravitational-wave detectors will require coatings with a strain thermal noise reduced by a factor of 25 compared to Advance present investigations of HfO2 doped with SiO₂ as a new coating material for future Our measurements show an extinction coefficient of $k = 6 \times 10^{-6}$ and a mechanical loss of 8×10^{-4} at 10 K, which is a factor of 2 below that of SiO₂, the currently used low refractive oating material. These properties make HfO2 doped with SiO2 ideally suited as a low-index material for use with a-Si in the lower part of a multimaterial coating. Based on these results, we present a multimaterial coating design which, for the first time, can simultaneously meet the strict requirements on optical absorption and thermal noise of the cryogenic Einstein Telescope ETM abs.=3.4ppm 0.5 T=4.4ppm 0 500 1000 1500 2000 2500 3000 3500 4000 (b) ITM Ta₂O₅ abs.=3.4ppr SiO.:HfO 0.5 =6000ppm 0 500 1000 1500 2000



Crystalline Coatings an alternative concept

- Orange line: Current LIGO/Virgo coatings cooled (for comparison)
- Blue area: Crystalline coatings show low CTN
 - upper boundary: <u>AlGaP/GaP</u>
 - → can be grown directly on silicon (matching lattice structure required for growth), absorption needs reduced
 - o lower boundary <u>GaAs/AlGaAs</u>
 → low absorption, needs to be grown on GaAs wafers: too small
- Crystalline coatings: Promising
 - variety of materials can be grown on silicon (or also on other materials + transfer)
 - Within ETPF: J.P. Locquet, Uni Leuven

Other ideas: amorphous and crystalline hybrids

Hamburg: amorphous coatings with <u>crystalline toplayer</u>

ET-LF design (2020 update)





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The End!

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 - variety of materials can be grown on silicon (or also on other materials + transfer)
 - Within ETPF: J.P. Loquet, Uni Leuwen

Other ideas: amorphous and crystalline hybrids

- Hamburg: amorphous coatings with crystalline top layer
- Glasgow: SiO₂ implantation into silicon substrate



